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1 Introduction

Recently, all-inorganic cesium lead-halide (CsPbX₃, X = Cl, Br, and I) perovskite films have grown in popularity due to their superior optical properties such as high photoluminescence quantum yields $(PLOYS),^{1,2}$ narrow emission line widths, 3,4 wide</sup> emission spectra tunability, $5-7$ and low material costs. $8,9$ These properties make them a prime candidate for use in solar cells,¹⁰⁻¹² white light-emitting diodes, $13-15$ displays, 16 photodetectors, $17,18$ laser and so on.¹⁹⁻²¹ The fabrication of high quality $CsPbX₃$ perovskite films is a prerequisite for numerous applications. For example in laser applications, perovskite films act as the gain medium and the resonant cavity. The film quality, including its smoothness, the homogeneousness of its large area, and thickness, are fundamental for realizing low threshold and high gain coefficients.

There are numerous ways to fabricate $CsPbBr₃$ films. The most common methods are spin-coating and thermal evaporation. Spin-coating is a facile preparation approach, which is achieved by dropping a $CsPbBr₃$ solution onto the substrate while rotating at a high speed. Thus, making this method very

A simple multiple centrifugation method for largearea homogeneous perovskite CsPbB $r₃$ films with optical lasing†

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Large scale cesium lead-halide (CsPbX₃, X = Cl, Br, and I) perovskite films have become the basis of laser applications. Common fabrication methods such as spin-coating and thermal evaporation have a tradeoff between high quality and low cost. Herein, we reported a facile method for preparing a large area homogeneous perovskite $CsPbBr₃$ film via a multiple centrifugal deposition and solvent annealing (MCDSA) method. This method is superior because it can control the thickness (180 nm to 880 nm) of the film, ensure the film is crack and pinhole free, has a large area (2.5 cm \times 2.5 cm), and has a low surface roughness (a root mean square of 32 nm). Multiple times of centrifugation and solvent annealing in the MCDSA method are key to improving the quality of the film as well as the laser performance. With increased centrifugation cycles from one to four, the thickness of the film increases from 180 nm to 880 nm, leading to a decrease in the laser threshold from 18.1 μ J cm⁻² to 14.2 μ J cm⁻² and an increase in the gain coefficient from 78.5 cm⁻¹ to 112.7 cm⁻¹. When solvent annealing is employed, the gain coefficient is further increased to 122.7 cm^{-1} . Open Access Article. Published on 06 July 2020. Downloaded on 12/1/2024 1:58:24 AM. This article is licensed under a [Creative Commons Attribution-NonCommercial 3.0 Unported Licence.](http://creativecommons.org/licenses/by-nc/3.0/) **[View Article Online](https://doi.org/10.1039/d0ra04259e) [View Journal](https://rsc.66557.net/en/journals/journal/RA) [| View Issue](https://rsc.66557.net/en/journals/journal/RA?issueid=RA010043)**

easy to operate. The as-prepared $CsPbBr₃$ films usually result in inhomogeneous samples (having numerous cracks and uncovered pin-holes) with relatively large surface roughness. Moreover, this method wastes a serious amount of material, almost 99% of the source is out of use, making it unsuitable for mass production. Since spin-coating does not deposit compact and homogeneous films with large areas, numerous post-treatments are necessary to improve the morphology and crystallinity of the films. $22-25$ Thermal evaporation is another effective way to fabricate large-scale $CsPbBr₃$ films. In this method, the source material is placed in an evaporator and the high temperature deposits the source material on the substrate, making the film compact and homogeneous over a large area. In comparison to spin-coating, the thermal evaporation method can produce $CsPbBr₃$ films with better crystalline qualities, lower defect densities, and highly flat and smooth surfaces. In particular, thermal evaporation has shown great success in creating highquality nanostructures with controllable thickness. However, the synthesis process is complicated and requires dedicated equipment. Designated experimental conditions are also needed, leading to increased costs of the films.²⁶⁻³⁰ Overall, both spin-coating and thermal evaporation do not satisfy the requirement of high quality and low cost simultaneously. Thus, it is highly desirable to develop a new method that aims to produce $CsPbBr₃$ films with good surface characteristics in an inexpensive manner.

In this study, we develop a multiple centrifugal deposition and solvent annealing (MCDSA) method for the large scale

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Fig. 1 The flow diagram of the MCDSA method

fabrication of $CsPbBr₃$ films with low surface roughness, low cost and good stability.³¹–³⁴ By changing the repetition times of the centrifugation process, the thickness of the $CsPbBr₃$ films can be controlled. Due to the high quality of the films, with a low surface roughness (root mean square of 32 nm) and a large area (2.5 cm \times 2.5 cm), the as-prepared CsPbBr₃ films show good laser performance. The measured ASE threshold and the gain coefficient are 14.2 μ J cm⁻² and 122.7 cm⁻¹, respectively. We note the recent report of colloidal quantum dot films fabricated using a centrifugal casting method.^{35,36} Though the films are crack-free and macroscopically uniform over large areas, the films are thin, making them only suitable for

photodetector rather than laser applications. Thus, this work is the first report of a simple preparation and low cost method for obtaining $CsPbBr₃$ films with large area homogeneity, a low laser threshold, and a high gain coefficient, which has promising applications in the optical lasing field.

2 Results and discussion

2.1 Preparation of $CsPbBr₃$ films

Fig. 1 illustrates the typical MCDSA method, which includes three steps: (1) the preparation of $CsPbBr₃$ quantum dots (QDs) by mixing toluene with a dimethylsulfoxide (DMSO) solution

Fig. 2 (a) The XRD pattern of the CsPbBr₃ film. (b) High-resolution XPS spectra of Cs3d, (c) Pb4f, and (d) Br3d. (e) SEM image. (f) The PL intensity and absorption of the CsPbBr₃ film.

Fig. 3 The AFM pattern of the CsPbBr₃ films (a) S_A , (b) S_B , and (c) S_C .

containing oleic acid (OA), oleylamine (OAm), CsBr, and PbBr₂; (2) multiple times of centrifugation by putting the substrate in a freshly prepared $CsPbBr₃$ QD solution; (3) solvent-gas atmosphere annealing by putting the substrate in a closed cuvette surrounded by alcohol and toluene vapors (see details in the ESI†).

X-ray diffraction (XRD) of the CsPbBr₃ perovskite film in N_2 atmosphere was recorded and is shown in Fig. 2(a). The strong intensity of the diffraction peaks indicates the good crystallinity of the film. Most of the peaks are in agreement with the standard (rhombic) CsPbBr₃ (PDF#18-0364). The XRD pattern of the $CsPbBr₃$ perovskite film in an air atmosphere was also measured. The presence of $PbBr₂$ proved that an incomplete reaction occurred during the fabrication process (Table S2 in ESI†). A stability test conducted on the PL intensity indicated

that the PL intensity is stable if stored in a N_2 atmosphere rather than an air atmosphere (Table S3 in ESI†). The X-ray photoelectron spectroscopy (XPS) results shown in Fig. 2(b)–(d) display typical Cs peaks at 724.3 and 738.2 eV, Pb peaks at 137.9 and 142.7 eV and the Br peaks at 67.7 and 68.8 eV. From the SEM image in Fig. $2(e)$, we can see that the film is homogeneous and compact over a large area. No pinholes can be found. The absorption/photoluminescence (PL) spectrum of the $CsPbBr₃$ films (Fig. $2(f)$) displays an obvious peak at 516/529 nm, which is similar to that of the CsPbBr₃ QD solution shown in Fig. S1 in the ESI.†

One advantage of the MCDSA method is its ability to control the thickness of the film simply by changing the number of centrifugation steps. Three samples (labeled S_A , S_B , and S_C) were fabricated using the MCDSA method with repetition numbers of

Fig. 4 The AFM pattern of the CsPbBr₃ film S_A (a) direct annealing (b) solvent annealing

Fig. 5 The schematic of the ASE measurement.

one, two, and four, respectively. The centrifuge time and speed were kept constant as 2 minutes and 8500 rpm. The thicknesses of the films were measured via atomic force microscopy (AFM), as shown in Fig. 3.³⁷ For samples S_A , S_B , and S_C , the measured thicknesses were 180, 500, and 880 nm, respectively, confirming the effective control of the film thickness using the number of centrifugation cycles.

Another advantage of the MCDSA method is the superiority of the surface morphology film. As shown in Fig. $4(b)$, the film obtained using the MCDSA method is a smooth $CsPbBr₃$ film with root mean square (RMS) of 32 nm. The third step of the MCDSA method, namely solvent-gas atmosphere annealing, is believed to be key for the formation of a smooth film. In a control experiment, the CsPbBr₃ films were annealed directly without a solvent-gas atmosphere (sample S_A). The resulting film showed pinholes and cracks and had an increased RMS of 37.8 nm, as shown in Fig. 4(a). It is well known that polar solvents play an important role in the dissolution and recrystallization of halide perovskites.³⁸ A polar solvent-gas atmosphere can partially dissolve the surface of the film, followed by the recrystallization of the perovskite to reveal a more compact, smooth, and uniform surface.

2.2 Laser measurement

A schematic of the ASE measurement is illustrated in Fig. 5. The excitation source used for this work was a Ti:sapphire oscillator/ amplifier. The latter produced a \sim 120 fs duration and had an 800 nm wavelength laser output with a repetition rate of 1 kHz.

Fig. 6 The PL spectra of the (a) S_{D} , (b) S_{C} , (c) S_{A} , and (d) S_{B} samples.

Fig. 7 (a) The ASE intensity of the S_C sample versus the intensity of the pump laser. (b) The PL intensity of the S_C sample versus the excitation length.

The output divergence angle after collimation is approximately 0.65 mrad. Using a beta barium borate (BBO) crystal, the output wavelength is converted to 400 nm. The pump beam is focused

by a cylindrical lens on the sample, while the ASE signal is collected by a lens to the spectrograph.

The ASE property of the CsPbBr₃ films (Fig. 6) depicted that the CsPbBr₃ films under a low pump power present a broad

Fig. 8 The time resolution of the PL spectrum of the solution (a). The time resolution of the PL spectra of the film with the pump intensities of (b) 10.7 μJ cm⁻² and (c) 25.0 μJ cm⁻².

spontaneous emission (SE) with a peak centered at 529 nm. With increasing pump density, a peak located at 536 nm emerges and quickly becomes dominant. Meanwhile, the FWHM of the emission spectrum narrows sharply, which signifies the transition from an SE process into the ASE regime. The measured emission spectra of the S_D (about 880 nm without solvent annealing) and S_C (about 880 nm with solvent annealing) samples, are shown in Fig. 6(a) and (b), respectively. It can be found that the intensity of the ASE signal is enhanced distinctly under the same pump intensity after solvent annealing (Table S1 in the ESI†). The threshold is decreased from 16.2 μ J cm $^{-2}$ to 14.1 μ J cm $^{-2}$. Moreover, the gain coefficient is increased from 112.7 cm^{-1} to 122.7 cm^{-1} , suggesting that solvent annealing can slightly improve the gain coefficient of the CsPbBr₃ film. A possible reason for the effect of solvent annealing is the improved surface morphology, which decreases the surface scattering of the film, thus decreasing the threshold and increasing the gain coefficient. The emission spectra of the S_A (about 180 nm with solvent annealing) and S_B (about 500 nm with solvent annealing) samples are shown in Fig. 6(c) and (d). Compared to Fig. 6(c) and (d) with Fig. 6(b), it is obvious that with the increase in the thickness from 180 nm to 880 nm, the intensity of the ASE increases. As a result, the threshold decreases from 18.1 μ J cm $^{-2}$ to 14.2 μ J cm $^{-2}$, and the gain coefficient increases from 78.5 cm^{-1} to 122.7 $\mathrm{cm}^{-1},$ as shown in Table S2 (ESI†). By comparing Tables S1 and S2 in the ESI,† it can be found that the thickness rather than solvent annealing is the dominant factor that affects the threshold and gain coefficient. Paper

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Fig. 7(a) shows the plot of the ASE intensity versus the intensity of the pump laser of the S_C sample. Only spontaneous emission occurs under low pump intensity. When the pump intensity increases beyond the threshold, the emission intensity rises rapidly. The threshold of the film is 14.2 μ J cm $^{-2}$, and the full width at half maximum (FWHM) is 28 nm when the pulse energy is 9.4 μ J cm $^{-2}$. By further increasing the pulse energy to 45.5 μ J cm⁻², the emission FWHM of the CsPbBr₃ film decreases to 6 nm. The gain coefficient, a key factor of the gain medium, was measured as 122.7 cm^{-1} by changing the length of the slit, as depicted in Fig. 7(b). The output intensity shows an"S" shape with an increased excitation length. When the stripe length reaches the threshold value where propagation losses are compensated by optical amplification, the PL spectrum starts to show an additional ASE component that increases with the strip length. This is the reason why the output intensity at extremely large stripe lengths will deviate from the first six data.39,40 The plots of the ASE intensities versus the intensity of the pump laser of the S_A , S_B , and S_D samples are also shown in Fig. S2 (ESI†). It can be concluded that the ASE behavior can be optimized greatly through increasing the thickness of the film or performing a solvent annealing treatment.

We measured the emission lifetime using a streak camera (c5680-04/M, Hamamatsu). Fig. 8(a) shows the PL lifetime of the concentrated CsPbBr3 QD solution. The PL lifetime of the CsPbBr₃ QD solution contains 4.00 ns and 46.85 ns, which was fitted by a double-exponential function. Fig. $8(b)$ and (c) show the time domain spectra of the S_C sample. When the pump

intensity increased from 10.7 μ J cm⁻² to 25.0 μ J cm⁻², the measured PL lifetime decreased from 0.37 ns to 0.14 ns. This was caused by the increased proportion of the ASE signal from 55% to 90% due to the increased stimulated radiation probability. The time-resolved PL spectra are shown in Fig. S3 (ESI†).

3 Conclusions

In conclusion, we reported a simple MCDSA method for the preparation of large area homogeneous perovskite $CsPbBr₃$ films using multiple centrifugation cycle deposition and solvent annealing techniques. This method can prepare $CsPbBr₃$ films with a controllable thickness from 180 nm to 880 nm, large area $(2.5 \, \text{cm} \times 2.5 \, \text{cm})$, and low surface roughness (a root mean square is 32 nm). By comparing three samples with different thicknesses (180 nm, 500 nm, and 880 nm), it was shown that the threshold decreased from 18.1 μ J cm⁻² to 14.2 μ J cm⁻² and the gain coefficient increased from 78.5 cm^{-1} to 122.7 cm^{-1} with increasing thickness. By comparing a solvent annealed sample to a sample that did not undergo solvent annealing, it was shown that the threshold decreased from 16.2 μ J cm⁻² to 14.2 μ J cm⁻², while the gain coefficient increased from 112.7 cm^{-1} to 122.7 cm^{-1} . The results demonstrated that the threshold and the gain factor parameters can be optimized greatly through increasing the thickness of the sample and performing solvent annealing treatments.

Conflicts of interest

There are no conflicts to declare.

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